LISTING OF THE CLAIMS

- 1. (currently amended) A microheater for microfluidic devices comprising at least one microchannel <u>having a length</u> formed on a substrate and further comprising <u>at least one</u> conductor disposed in said microchannel <u>along a majority of the length of said microchannel</u>.
- 2. (original) A microheater according to claim 1 said conductor selected from the group consisting of metal, metal alloys, composites of organic conducting polymers and metals and organic conducting polymers; and implanted ions.
- 3. (original) A microheater according to claim 2 said conductor comprising an aluminum alloy comprising 99% aluminum and silicon and copper.
- 4. (original) A microheater according to claim 2 said conductor comprising implanted boron ions.
 - 5. (original) A microheater according to claim 1 said substrate comprising a wafer.
 - 6. (original) A microheater according to claim 1 said substrate comprising quartz.
 - 7. (original) A microheater according to claim 1 said substrate comprising borosilicate glass.
 - 8. (original) A microheater according to claim 1 said substrate comprising an oriented, boron doped, single side polished silicon wafer.
- 9. (original) A microheater according to claim 1 further comprising a glass layer disposed on said conductor.
- 10. (currently amended) A microfluidic device comprising at least one microchannel, said microchannel further comprising a microheater, said microheater comprising a <u>at least one continuous</u> conductor layer formed in <u>a majority of a length of said microchannel</u>.
- 11. (original) The device according to claim 10 said conductor selected from the group consisting of metal, metal alloys, composites of organic conducting polymers and metals and organic conducting polymers; and implantated ions.
- 12. (original) The device according to claim 10 said microchannel comprising a channel formed on a substrate said substrate selected from the group consisting of quartz and borosilicate wafers.

- 13. (original) A microheater according to claim 10 further comprising a glass layer disposed on said conductor layer.
- 14. (currently amended) A method for fabricating a microheater for a microfluidic device comprising the steps of:

providing a substrate;

patterning said substrate;

forming at least one microchannel in said substrate; and

forming a <u>at least one</u> conductor in <u>a majority of a length of</u> said <u>at least one</u> microchannel.

- 15. (original) The method according to claim 14, said step of forming said channel comprising etching said substrate.
- 16. (original) The method according to claim 14, said step of forming said conductor comprising ion implantation.
- 17. (original) The method according to claim 16, said ion implantation step comprising implanting in said channel boron.
- 18. (original) The method according to claim 14, said step of forming said conductor comprising forming a metal, metal alloy, organic conducting polymer or polymer-metal composite in said channel.
- 19. (original) The method according to claim 14 said step of forming said conductor comprising sputtering aluminum or an alloy thereof in said channel.
- 20. (original) The method according to claim 14 comprising the further step of applying a layer of glass over said conductor.